Search Notes			

Application No.	Applicant(s)	
10/633,093	MORI, KENICHIRO	
Examiner	Art Unit	•
D. Rutledge	2851	

SEARCHED				
Class	Subclass	Date	Examiner	
355	53,67,71, 77	9/18/2004	DR	
355	68	9/18/2004	DR	
250	205,548	9/18/2004	DR	
430	311	9/18/2004	DR	

INTERFERENCE SEARCHED			
Class	Subclass	Date	Examiner
355	53, 67	9/20/2004	DR
355	71, 77	9/20/2004	DR
250	205, 548	9/20/2004	DR
430	311	9/20/2004	DR

SEARCH NOT (INCLUDING SEARCH)
	DATE	EXMR
mask or reticle, desired or contact adj hole, second or auxiliary, pattern, best adj focus, highest adj resolution, none	9/18/2004	DR
un adj resolved, lamp or light or laser or source, distance, equation or condition or parameter or characteristic, hole adj	9/18/2004	DR
diameter, desired or contact adj hole, half adj pitch, auxiliary adj pattern, wavelength, numerical adj aperture	9/18/2004	DR
matrix, exposure, defocus\$3 or de adj focus\$3, location or position	9/18/2004	DR